
DRD1 School 2025

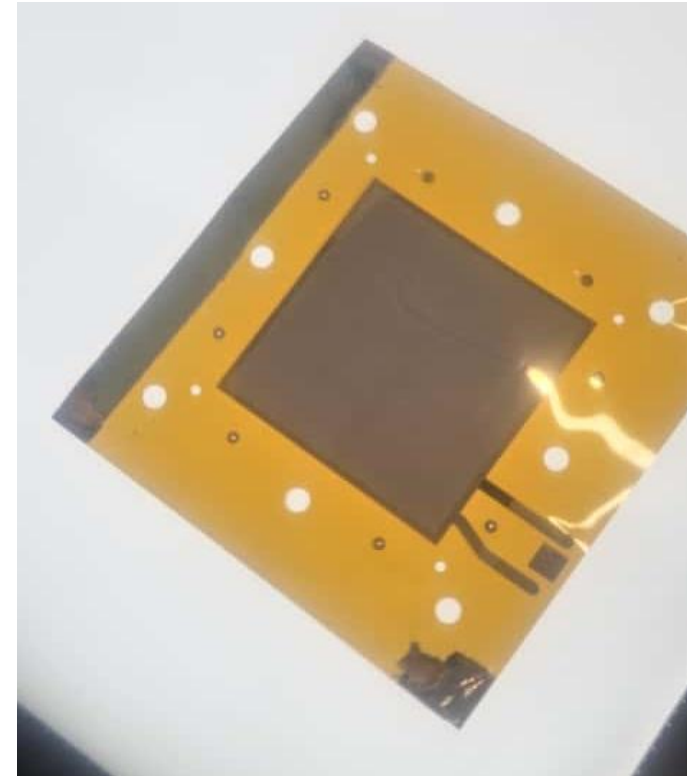
GEM Production MPGD Assembly, QA and Wire Assembly

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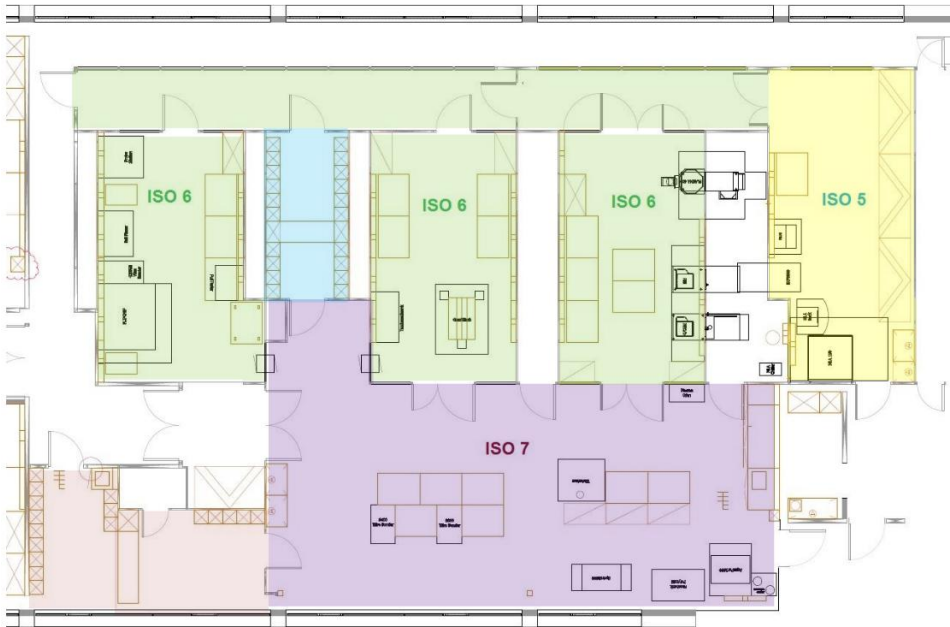
Goal of the Labcourse

- Understanding the production of a GEM
- Get hands-on experience in the clean room
- Perform a QA of the produced GEM
- Production of a wire based detector

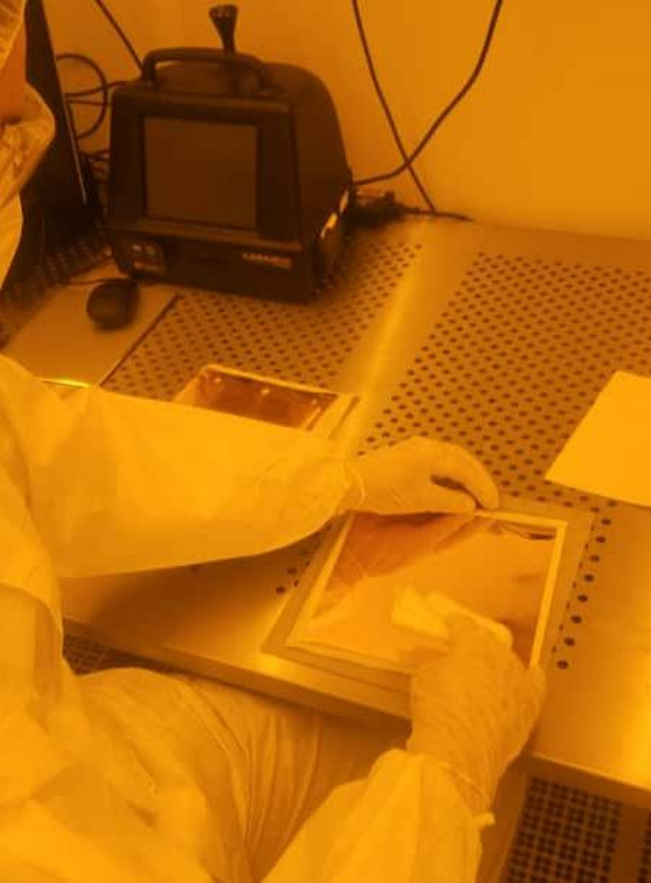


GEM Production at FTD Bonn

- Most work conducted in clean room
- Different iso standards (cleanest: iso 5)
- Mechanical & chemical workstations



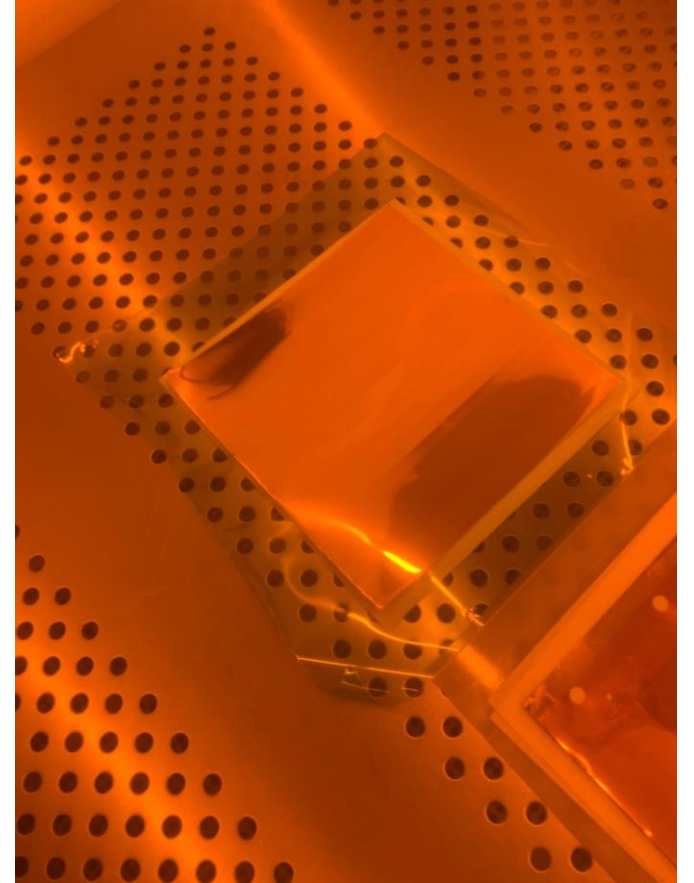
GEM Production: Hands On



Sample Preparation:
Cleaning, inspection

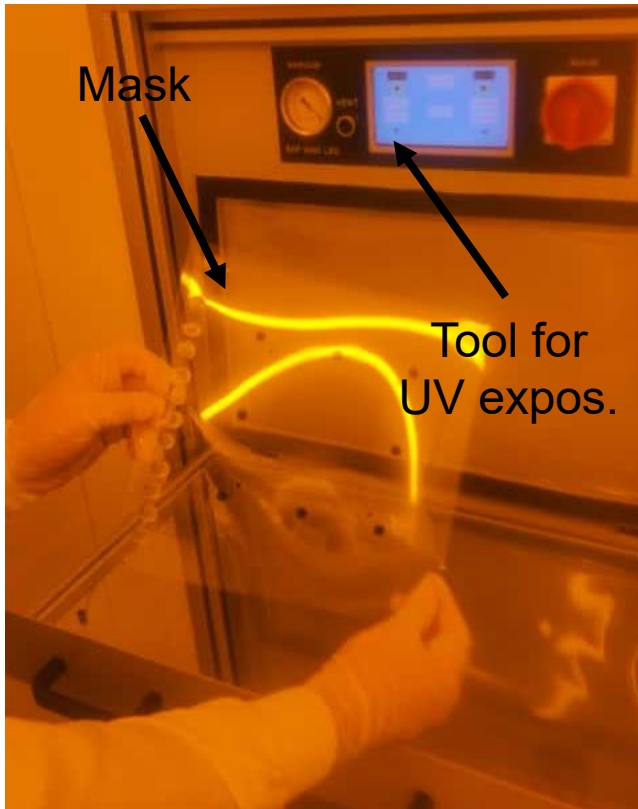


Photoresist application

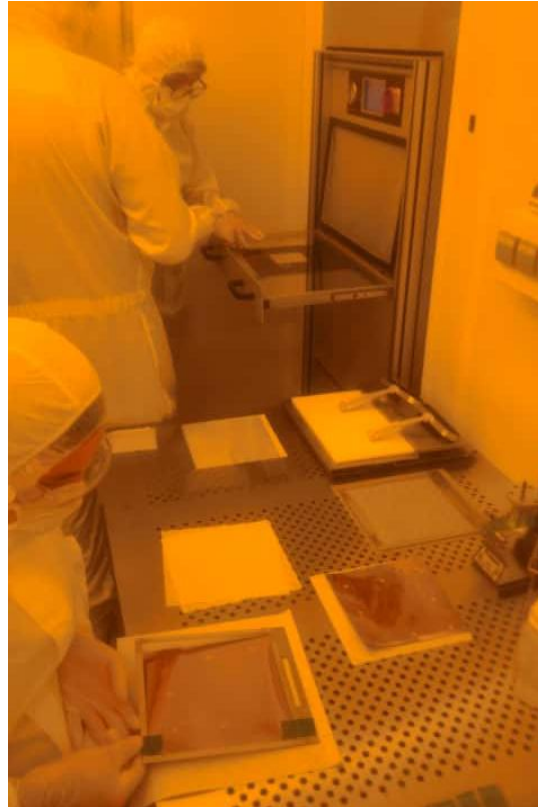


Finished sample
with photoresist

GEM Production: Hands On



Masking, exposure to UV
for ≈ 60 s, 50 % intensity

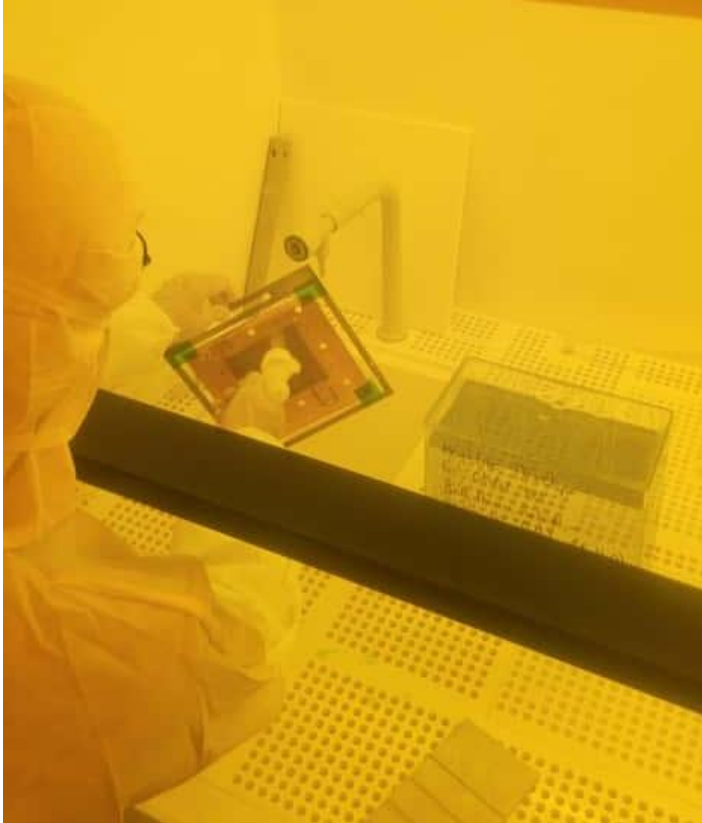


Putting sample
in metal frame

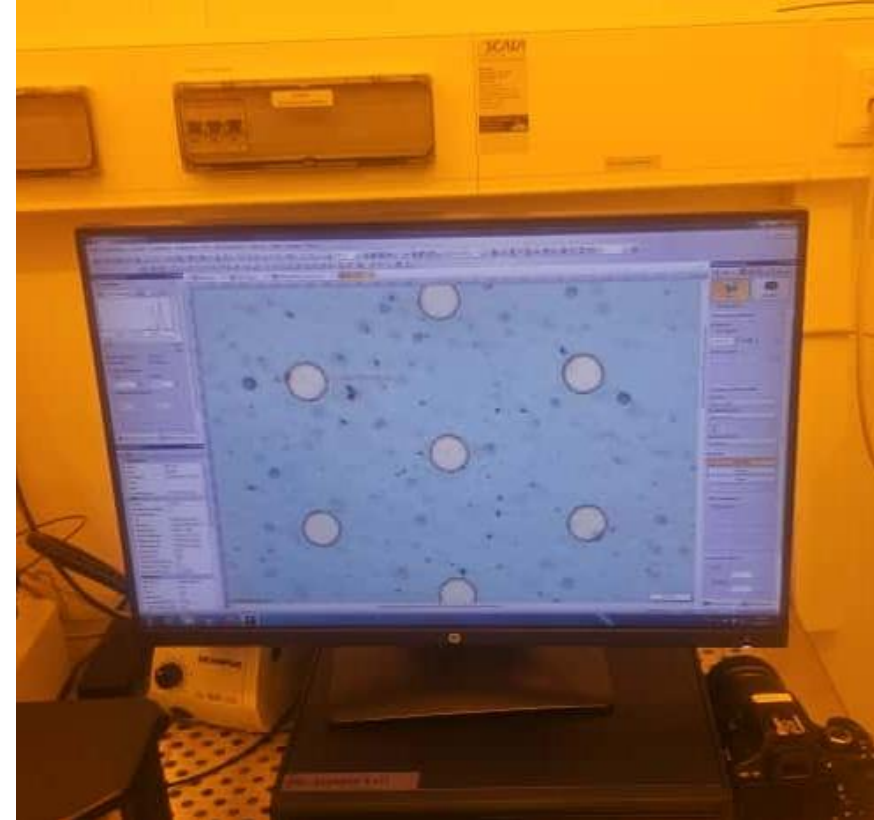


Development of the sample at the wet bench,
 ≈ 3 min, moving the sample from time to time

GEM Production: Hands On



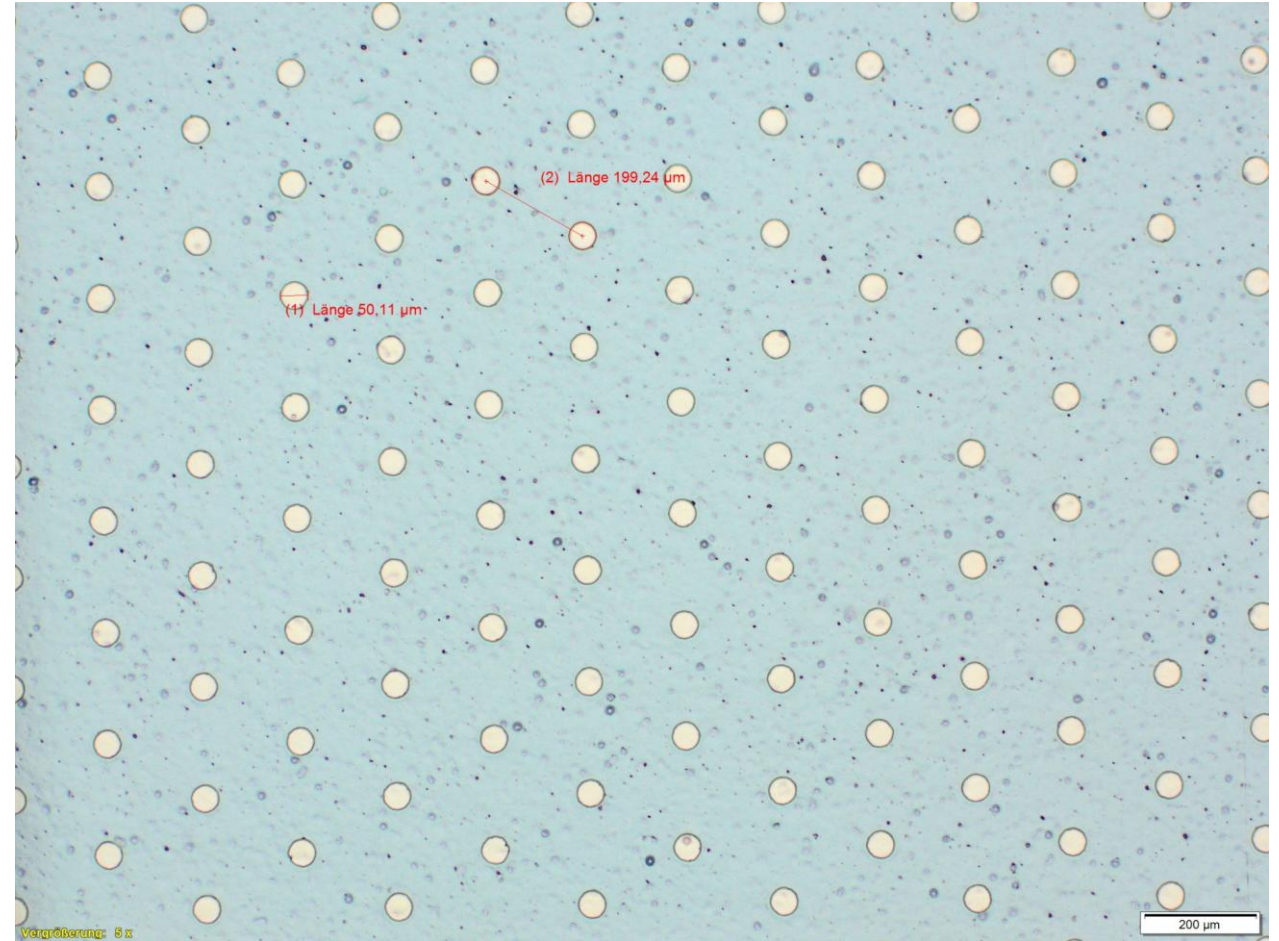
Cleaning excess developer



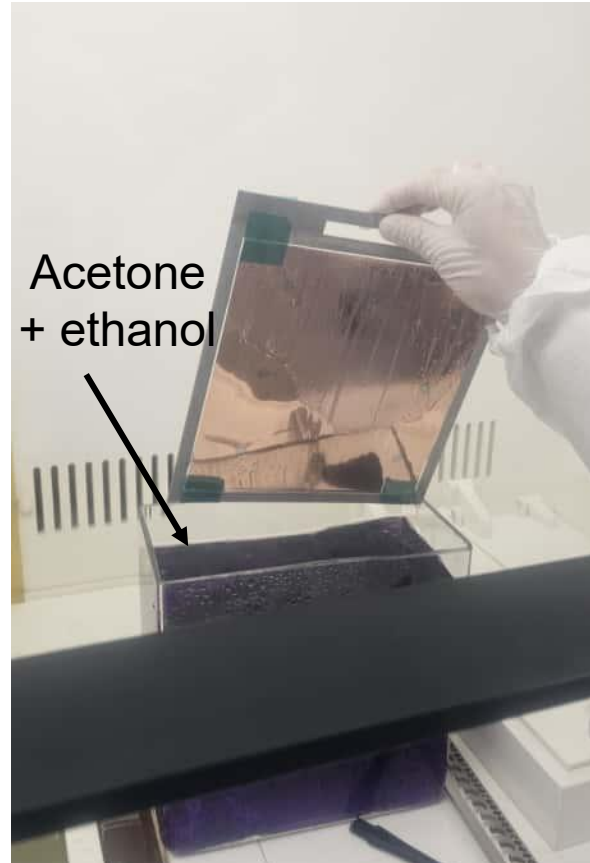
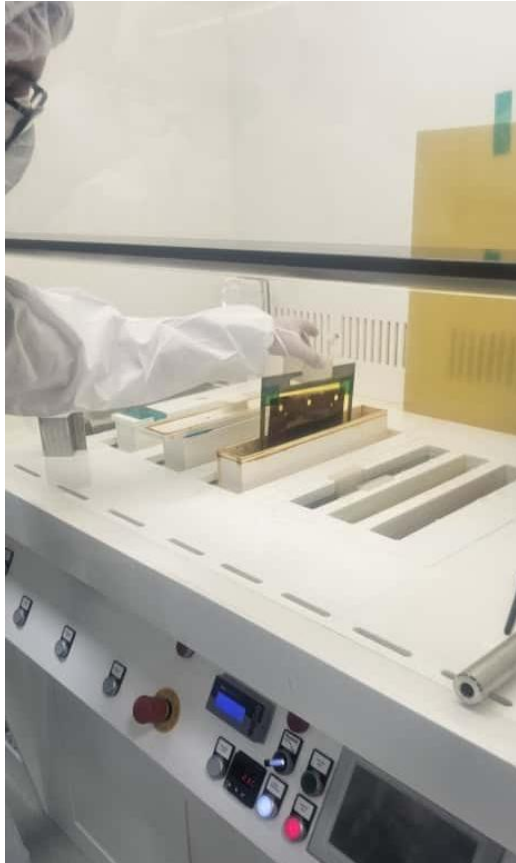
First inspection after development
using microscope

First Intermediate Results

- Multiple hole diameters, pitches checked
- Only rough sample
- But: Results seemed ok
 - Diameter: $\sim 50 \mu m$
 - Pitch: $\sim 199 \mu m$ (aim: $200 \mu m$)
- At this point: Happy with results (for now)



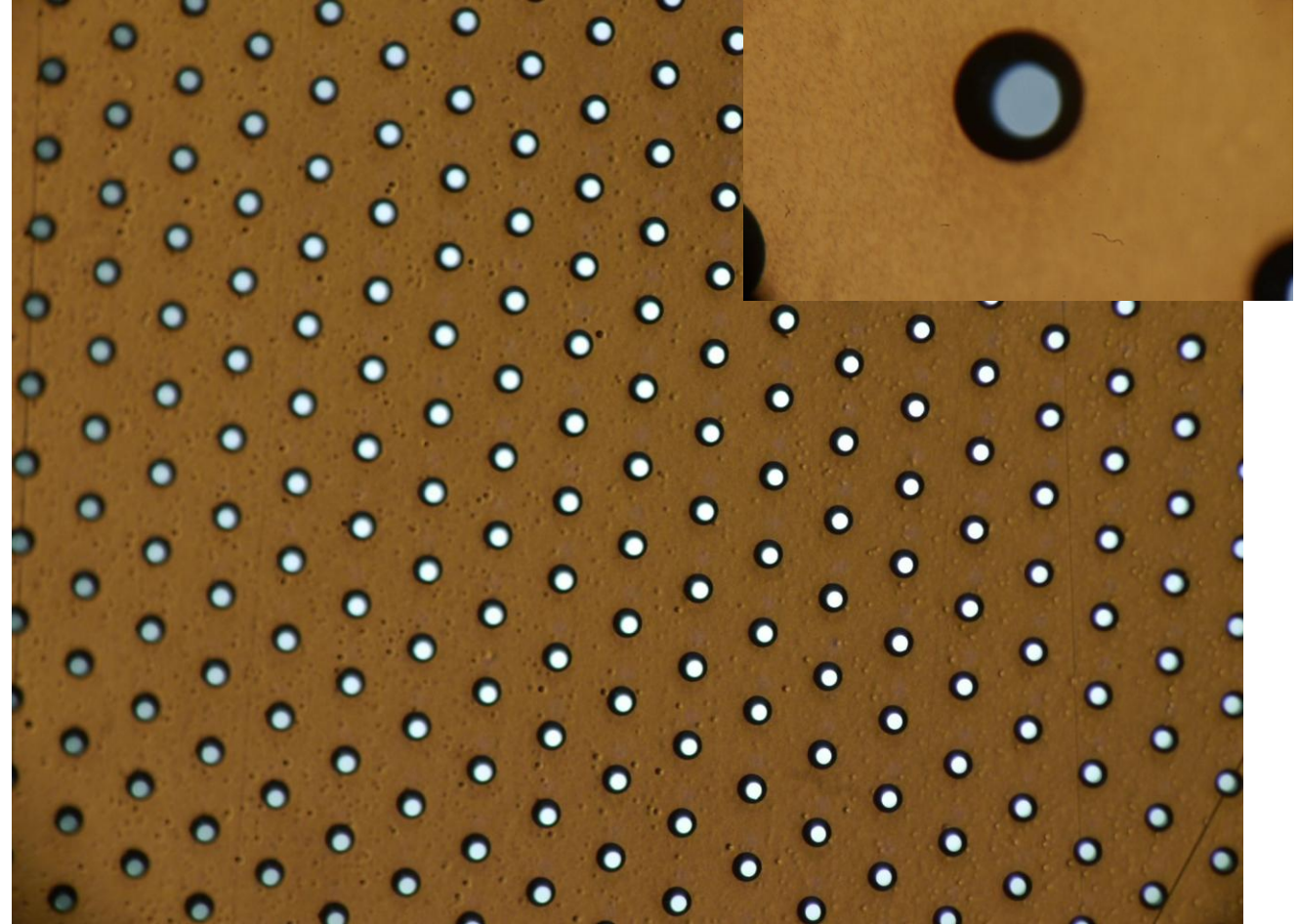
GEM Production: Hands On



Cu etching $\approx 2.5 \text{ min}$ (time sensitive!)
Photoresist stripping (until everything is removed)
Cr etching $\approx 30 \text{ s} - 1 \text{ min}$

Results After Etching Cycle

- Etching was successful
- Still: some irregularities
 - Not all holes edged perfectly round
 - Some topological defects on surface
- Reason: too long/short etching
- Not sufficient cleaning
- Uneven application of photoresist
- Use QA to assess influences



GEM QA – Optical

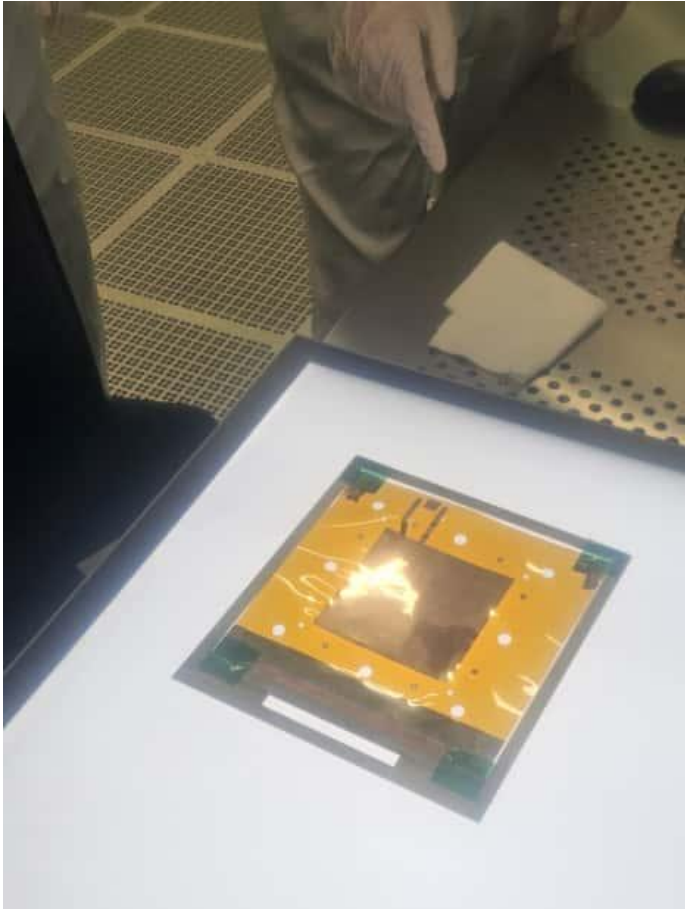
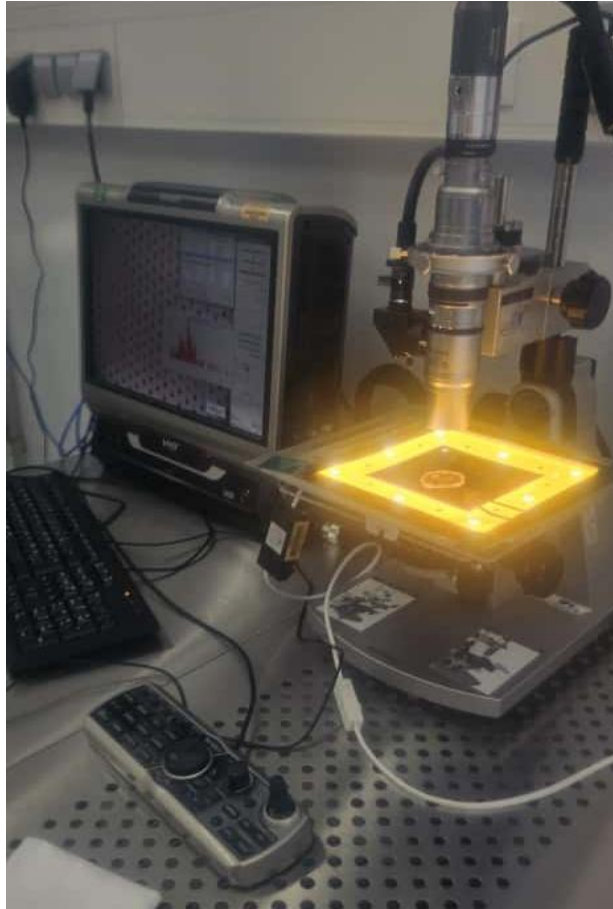


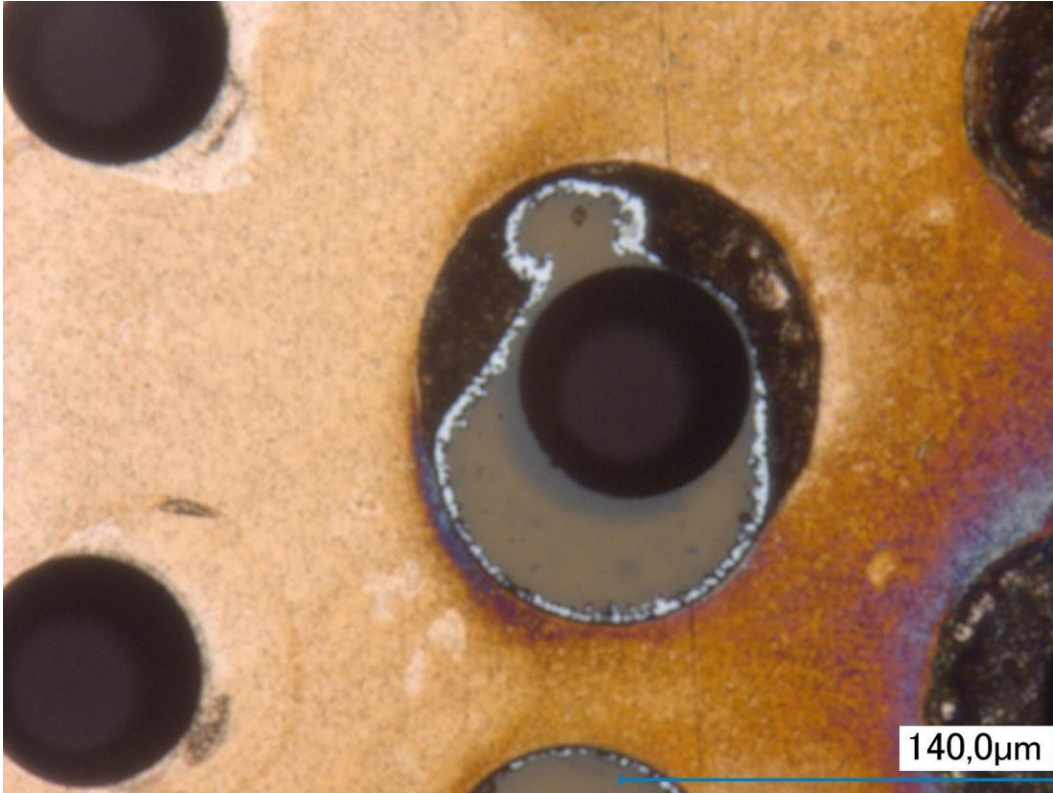
Table with background lighting



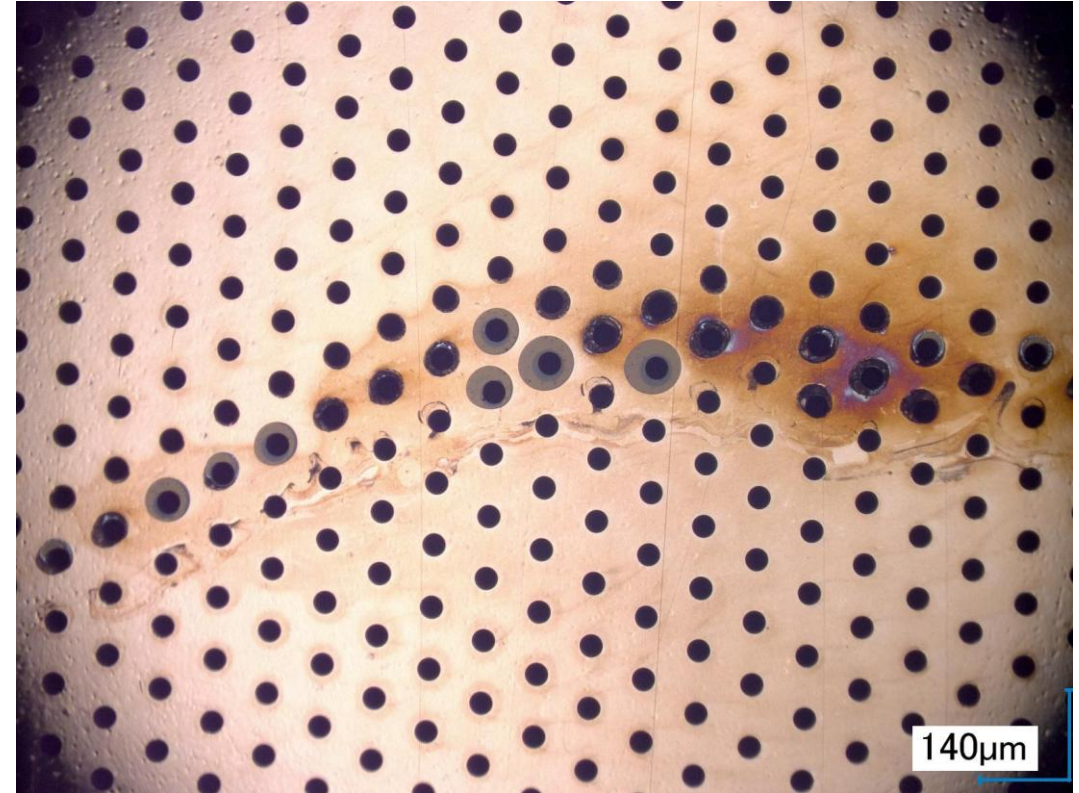
Microscope with semi-automatic analysis of e.g. hole diameter



GEM QA – Optical



Inner Diameter:
Top Right: $(46 \pm 1) \mu m$
Bot Left: $(44 \pm 1) \mu m$

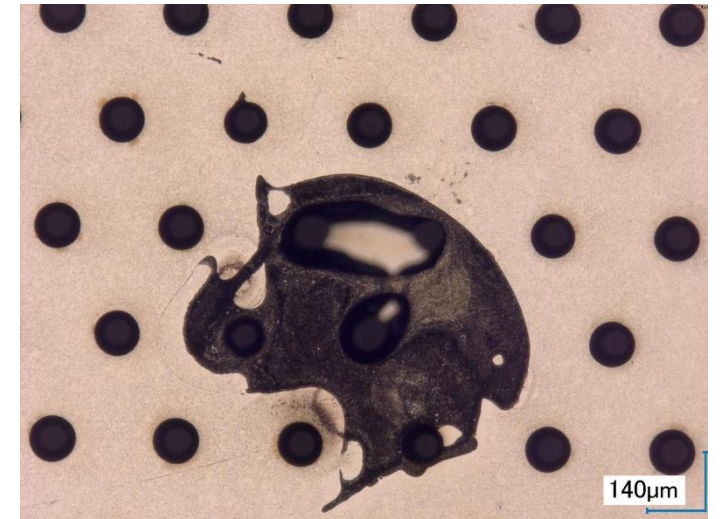
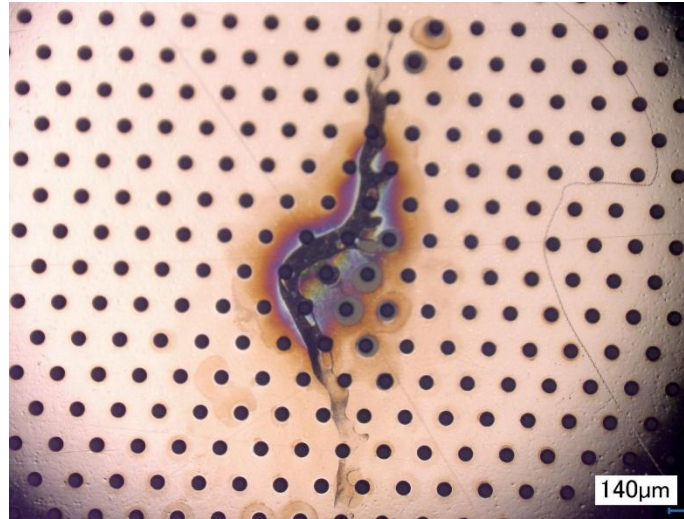
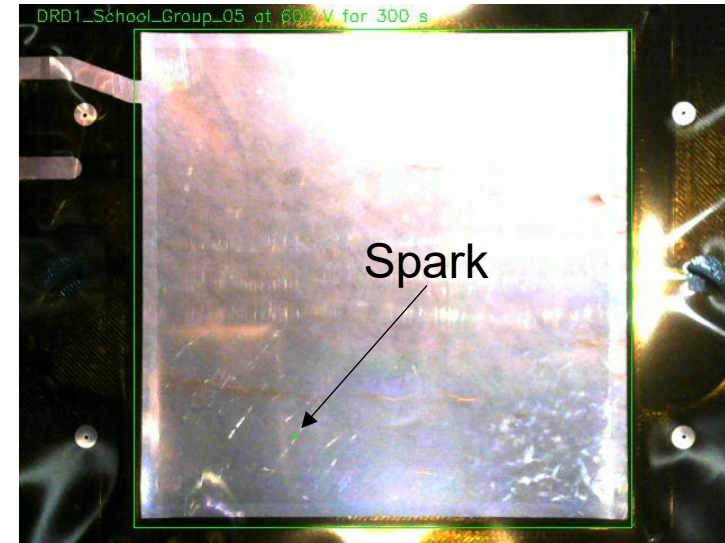
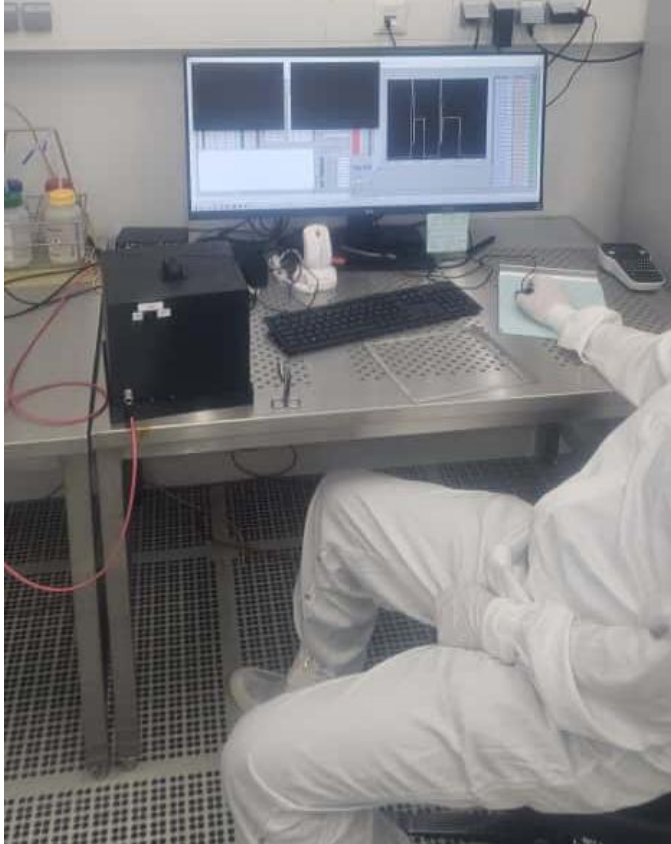


Outer Diameter:
Top Right: $(74 \pm 1) \mu m$
Bot Left: $(75 \pm 1) \mu m$

→ Especially inner diameter varies across GEM; etching not as good as thought

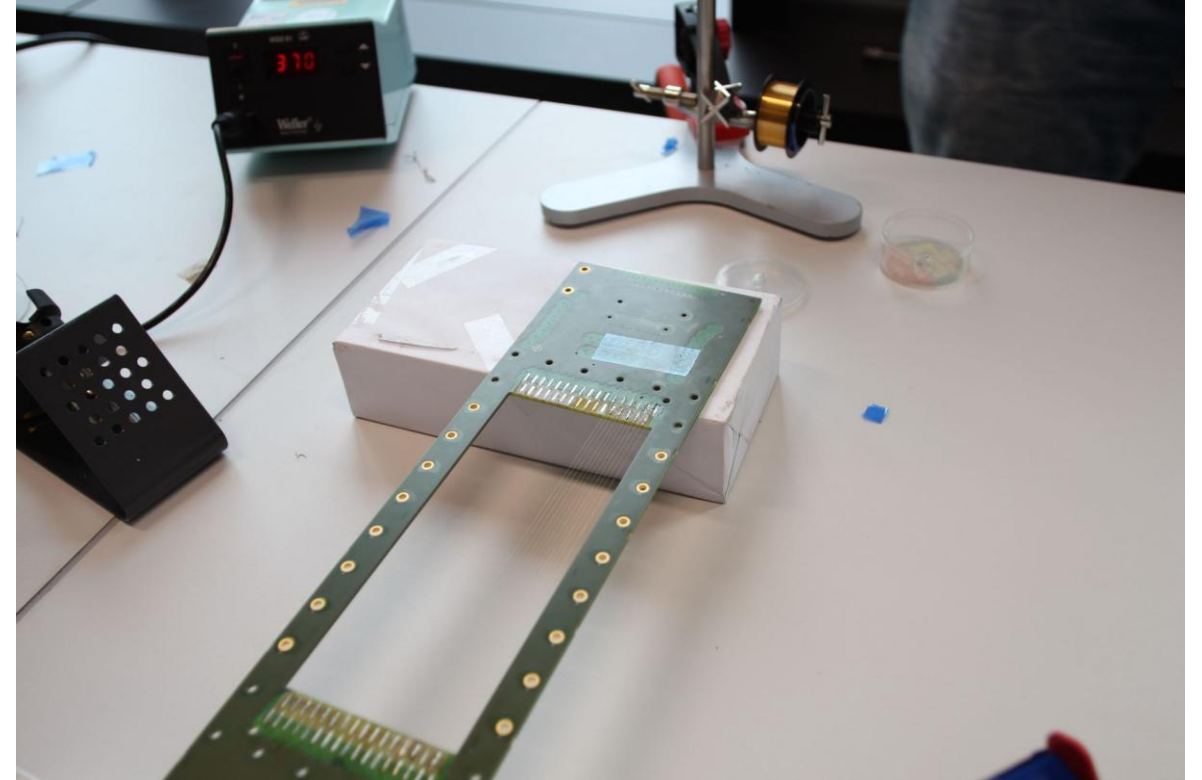
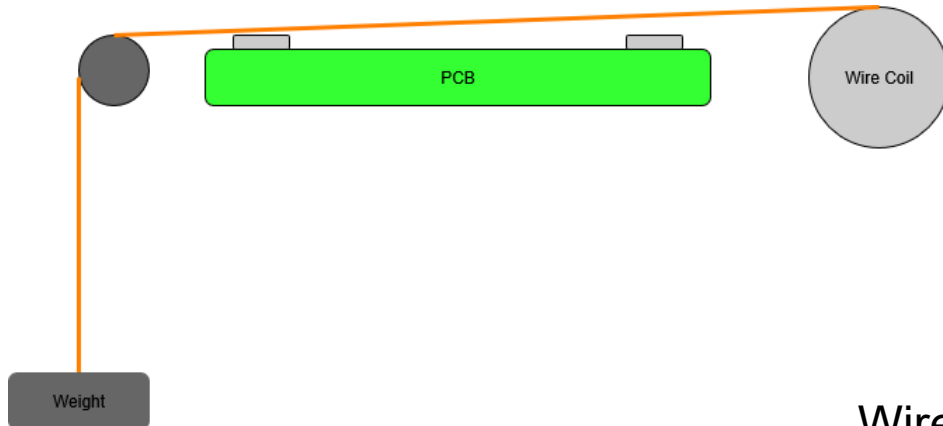
GEM QA – Electrical

- Place GEM in test box
- Apply HV to GEM, measure I_{leak}
- Webcam: Automatic discharge check



Wire Assembly

- Check wire breaking point
- Choose weight accordingly
- Should be in inelastic range
- Bring wire on height of PCB
- Tension wire without touching anything but rolls
- Otherwise: tension not optimal
- Solder onto PCB as straight as possible



Wire diameter: $30\ \mu\text{m} - 70\ \mu\text{m}$
Steady hands needed!

Thank You for Your Attention!



Especially, thanks to the DRD1 School organisation team
as well as the FTD in Bonn!